



Thermochromic Variable Emittance Coatings for Spacecraft Thermal Control Sydney Taylor, PhD

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- Personal Background
- Research Introduction and Motivation
- Designing a Variable Emittance Coating
- Fabricating and Characterizing a Variable Emittance Coating
- Thermal Vacuum Experiments and Feasibility Studies
- On-going Projects at NASA
- Thermal Technology Gaps Overview



Background









B.S. AAE '13



GE Combustion Intern Spring '12 GE PLM Intern Summer '13





Ph.D. Aerospace Engineering '20

NASA Space Tech Research Fellow '16-'20 Pathways Intern Spring and Summer '20 Full-Time at NASA January '21











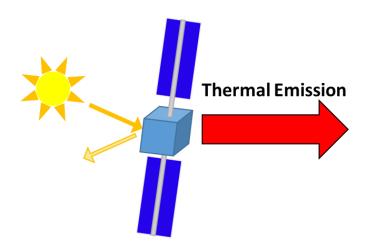
Research Introduction and Motivation



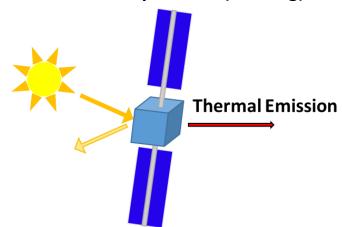
Variable Emittance Coatings

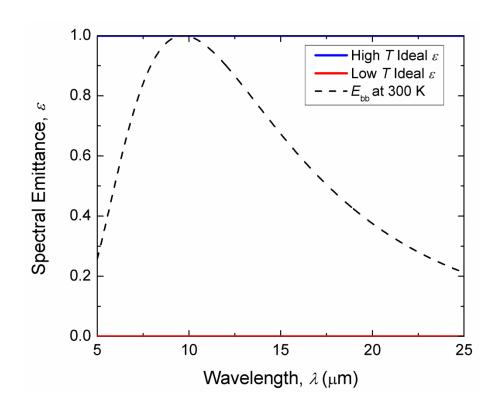


High Temperature (Cooling)



Low Temperature (Heating)





Ideal Broadband Emittance

- High Temp: $\varepsilon \approx 1$
- Low Temp: $\varepsilon \approx 0$



Thermochromic Coating Design

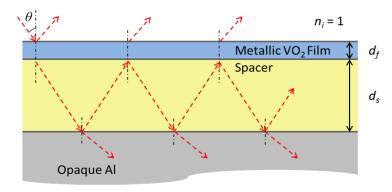


What is VO₂?

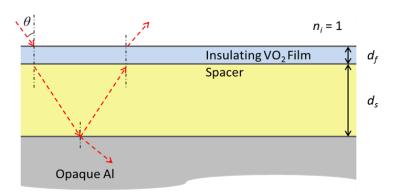
VO₂ is a thermochromic insulator to metal phase transition material

- At **high temperatures**, the Fabry-Perot resonance cavity is formed, leading to an emission enhancement near resonance wavelength of $\lambda = 10 \, \mu \text{m}$
- At low temperatures, the structure becomes highly reflective due to the high IR transmittance of the VO₂ and spacer material

Metallic VO_2 (T > 345 K)



Insulating VO_2 (T < 341 K)







Designing a Variable Emittance Coating



Modeling Properties of VO₂



Dielectric Functions (ε):

Insulator (T = 341 K):

$$\varepsilon_{d}(\omega) = \varepsilon_{\infty} + \sum_{j=1}^{N} S_{j} \frac{\omega_{j}^{2}}{\omega_{j}^{2} - i\gamma_{j}\omega - \omega^{2}}$$

Metallic (*T* > 345 K):

$$\varepsilon_{\rm m} = \frac{-\omega_p^2 \varepsilon_{\infty}}{\omega^2 - i\omega \omega_c}$$

Where:

 ε_{∞} = High frequency dielectric constant

 S_i = Phonon strength

 ω_{i} = Phonon frequency

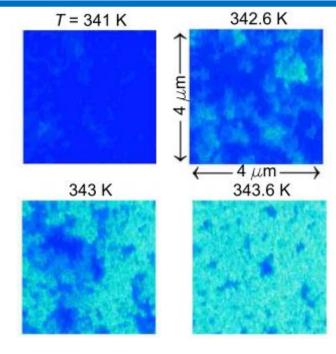
 ω_p = Plasma frequency

 $\omega_{\rm c}$ = Collision frequency

q = Depolarization factor

f = Filling Fraction

 γ_j = Damping Coefficient



In Transition (341 K< *T* < 345 K):

$$f \frac{\varepsilon_{\rm m} - \varepsilon_{\rm eff}}{\varepsilon_{\rm eff} + q(\varepsilon_{\rm m} - \varepsilon_{\rm eff})} + (1 - f) \frac{\varepsilon_{\rm d} - \varepsilon_{\rm eff}}{\varepsilon_{\rm eff} + q(\varepsilon_{\rm d} - \varepsilon_{\rm eff})} = 0$$

T (K)	f	q o	$q_{\scriptscriptstyle extsf{E}}$
341	0		
342	0.18	0.2	0.6
342.6	0.31	0.33	0.34
343	0.48	0.45	0.1
343.6	0.7	0.5	0
345	1.0		

Qazilbash et al., Phys. Rev. B, **79**, 075107 (2007) Barker et al., Phys. Rev. Lett., **17**, 1286 (1966)



Uniaxial Transfer Matrix Method



Indirect Calculation of Emittance:

$$\varepsilon_{\lambda}' = 1 - R_{\lambda}' - T_{\lambda}'$$

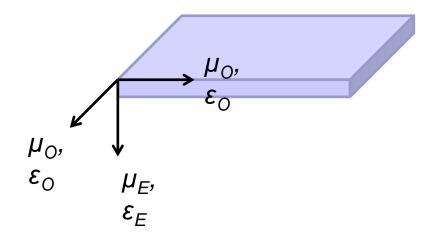
Transmittance:

$$T_{\lambda}^{',p} = \frac{\text{Re}(k_{z,N}^{p} / \varepsilon_{N,O})}{\text{Re}(k_{z,1}^{p} / \varepsilon_{1,O})} |\frac{1}{M_{11}}|^{2}$$

$$T_{\lambda}^{',s} = \frac{\text{Re}(k_{z,N}^{s} / \mu_{N,O})}{\text{Re}(k_{z,1}^{s} / \mu_{1,O})} |\frac{1}{M_{11}}|^{2}$$

Reflectance:

$$R_{\lambda}^{'} = rr^{*} = |\frac{M_{21}}{M_{11}}|^{2}$$



Z-direction Wavevector:

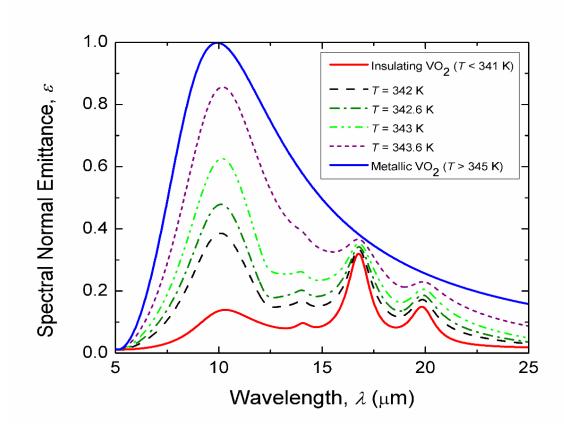
$$k_{z,i}^{s} = \sqrt{k_0^2 \varepsilon_{iO} \mu_{iO} - \mu_{iO} k_x^2 / \mu_{iE}}$$

$$k_{z,i}^{p} = \sqrt{k_0^2 \varepsilon_{iO} \mu_{iO} - \varepsilon_{iO} k_x^2 / \varepsilon_{iE}}$$



Thermochromics Design





Temperature-dependent emittance via the VO_2 phase transition

 VO_2 (d_f)

Dielectric Spacer (d_s)

200 nm Al

• VO₂ Thickness:

$$d_{\rm f} = 25 \, \mathrm{nm}$$

• Spacer Thickness:

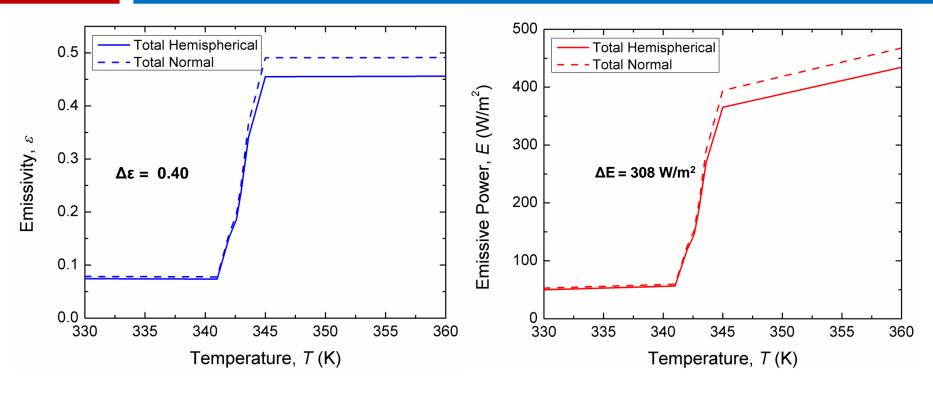
$$d_{\rm s} = \lambda_{\rm peak} / 4n \approx 730 \text{ nm}$$

where $\lambda_{\rm peak} = 10 \,\mu\text{m}$
 $n = 3.4$



Variable Emitter Total Emittance





Total Hemispherical Emissivity: Total Hemispherical Emissive Power:

$$\varepsilon = \frac{2\int\limits_{0.3\,\mu\mathrm{m}}^{40\,\mu\mathrm{m}} E_{bb} \int\limits_{0}^{\pi/2} \varepsilon_{\lambda}^{'}(T,\lambda,\theta) \cos\theta \sin\theta d\theta d\lambda}{\sigma T^{4}}$$

$$E_{\rm hem} = \varepsilon \sigma T^4$$





Fabricating and Characterizing a Variable Emittance Coating

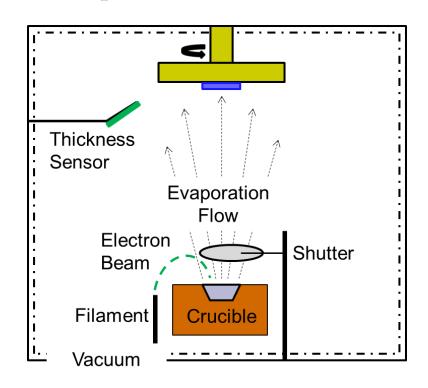


VO₂ Thin Film Fabrication



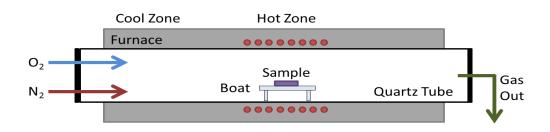
Electron Beam Evaporation:

• Deposit V thin film



Tube Furnace Oxidation:

Oxidize V thin film to VO₂



What furnace conditions do we need?

- Temperature
- Furnace Time
- O_2 flow rate
- N_2 flow rate

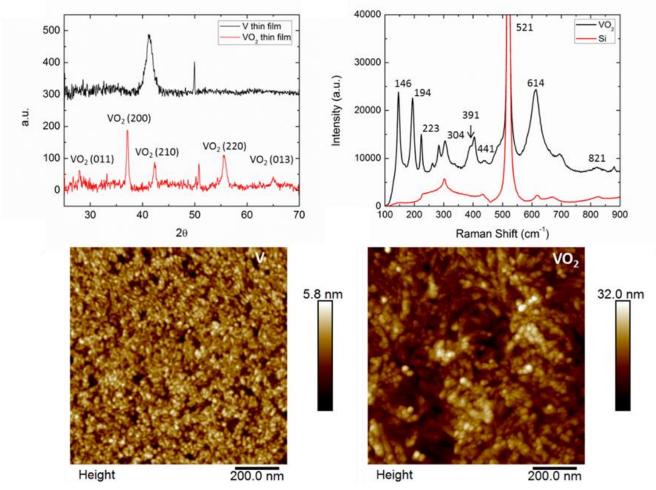
Conducted series of parametric studies to determine optimal

conditions



VO₂ Thin Film Characterization





- XRD pattern and Raman spectrum consistent with published results for VO₂ thin films
- Roughness of V and VO₂ is 0.79 nm and 4.79 nm respectively



VO₂ Thin Film IR Characterization

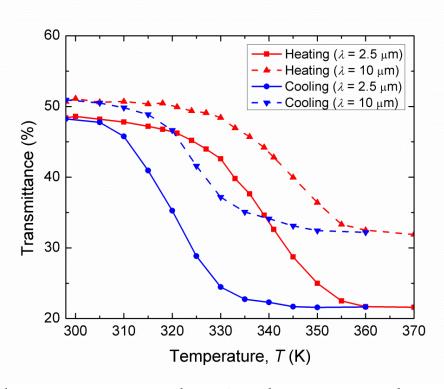


Transmittance of VO₂ Films

Transmittance (%) 40 30 Sample A $(T = 20 ^{\circ}C)$ Sample B $(T = 20 ^{\circ}C)$ Sample C (T = 20 °C) 10 Sample A ($T = 100 \,^{\circ}$ C) Sample B (T = 100 °C) Sample C (T = 100 °C) 15 20

Wavelength, λ (μ m)

Heating and Cooling Curves



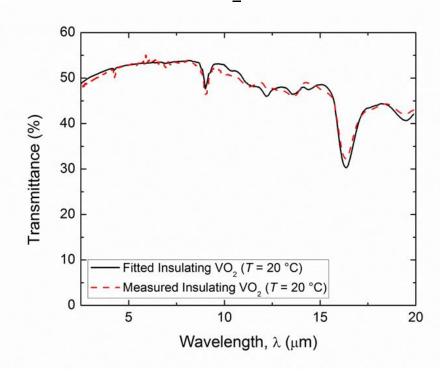
- Transmittance dips in fabricated films correspond to Si phonon modes
- All three fabricated VO₂ thin films had consistent transmittance
- Optical property models were developed for the VO₂ in IR range



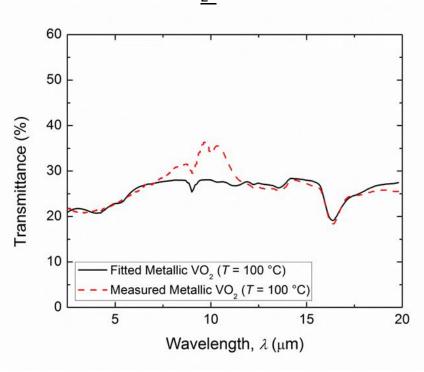
Optical Property Fitting



Insulating VO₂ Lorentz Fit



Metallic VO₂ Dispersion Fit



$$\varepsilon_{d}(\omega) = \varepsilon_{\infty} + \sum_{j=1}^{N} \frac{S_{j}\omega_{j}^{2}}{\omega_{j}^{2} - i\gamma_{j}\omega - \omega^{2}}$$

Least Squares Fit:
$$F = \sum_{k=1}^{N} (T_{\text{exp}} - T_{\text{theo}})^2$$

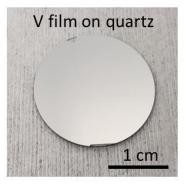
$$\varepsilon_{m}(\omega) = \varepsilon_{\infty} - \frac{\omega_{n}^{2}}{\omega^{2} + i\omega_{c}\omega} + \sum_{j=1}^{N} \frac{S_{j}}{1 - \omega^{2}/\omega_{j}^{2} - i\gamma_{j}\omega/\omega_{j}}$$

Ray Tracing:
$$T_{\text{theo}} = \frac{\tau_a \tau_s \tau}{1 - \rho_s \rho_b \tau^2}$$



VO₂ VIS/NIR Characterization

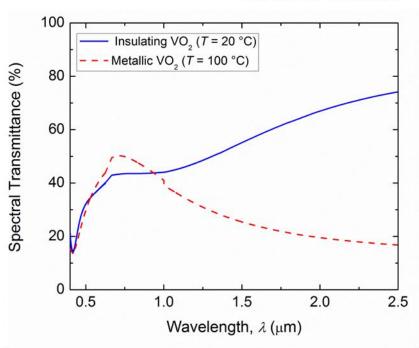


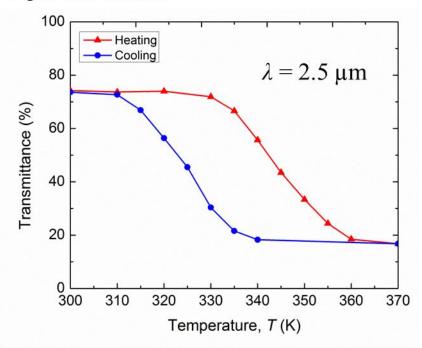


VO₂ film on quartz

Left: before oxidation

Right: after oxidation

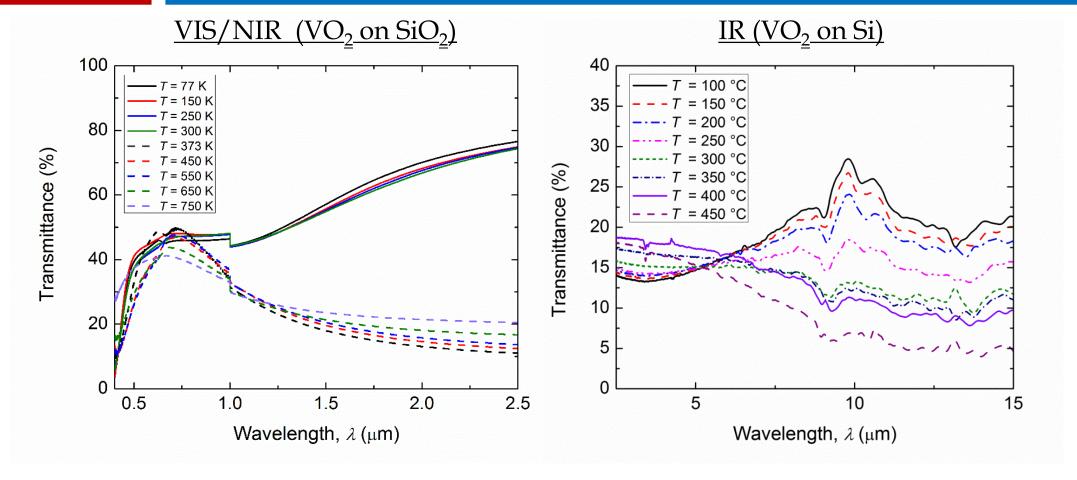






VO₂ Temperature Stability



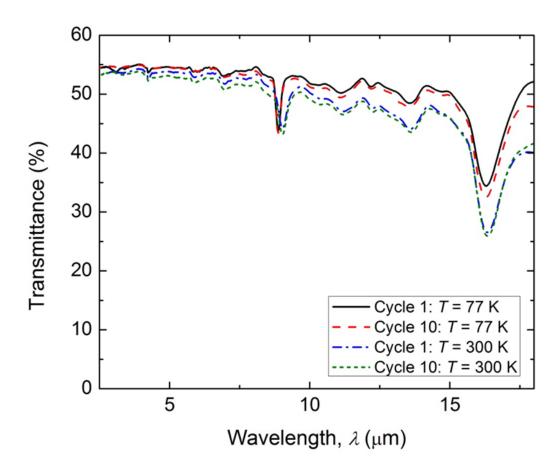


- VO₂ is stable up until 200 °C
- VO₂ is not sensitive to cryogenic temperatures in the VIS/NIR range



VO₂ Thermal Cycling Stability



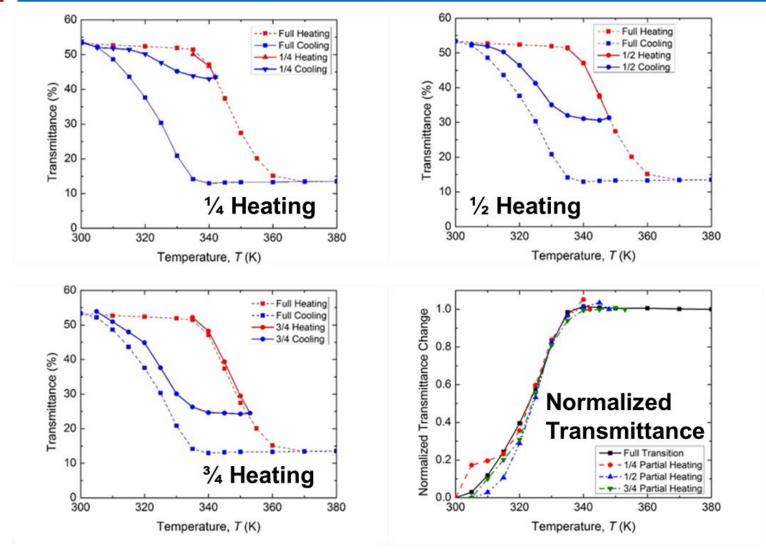


- Thermochromic performance of VO₂ is not affected by cryogenic temperatures
- VO₂ did not degrade after being subjected to 10 thermal cycles



Partial Heating Hysteresis



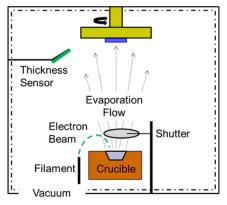




VO₂ FP Emitter Fabrication



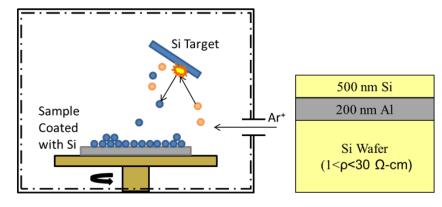
1 200 nm of Al with Electron Beam Evaporation (EBE)



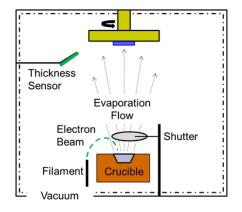
200 nm Al

Si Wafer
(1<ρ<30 Ω-cm)

2 500 nm of Si with RF Magnetron Sputtering

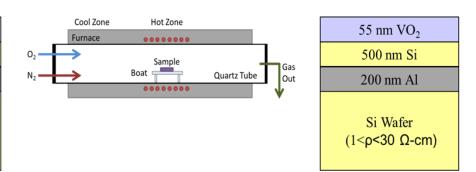


(3) 30 nm of V with EBE



30 nm V
500 nm Si
200 nm Al
Si Wafer
(1<ρ<30 Ω-cm)

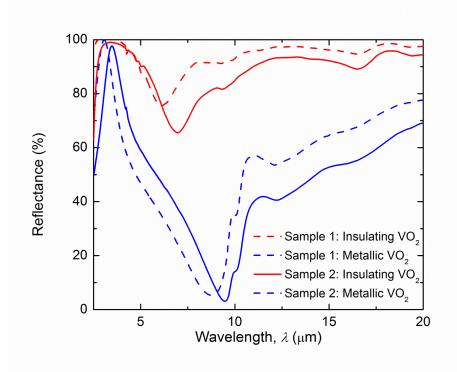
4 Oxidize in Tube Furnace

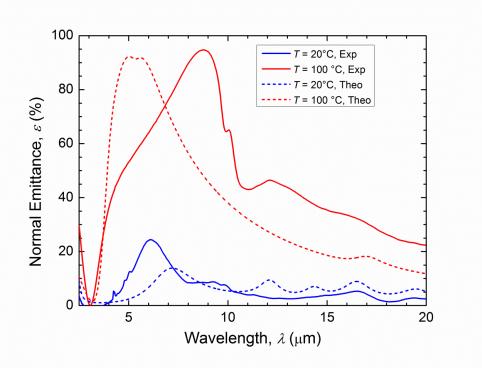




VO, FP Emitter Characterization





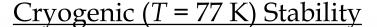


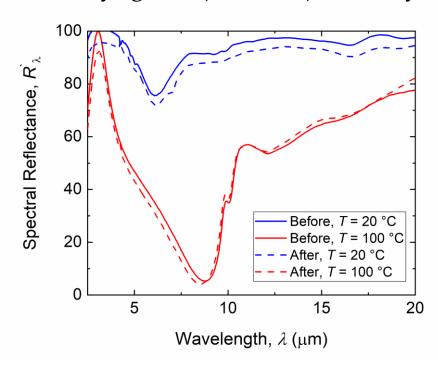
- Consistent behavior from both samples
- Significant change in mid-infrared reflectance upon phase transition
- Fabricated emitter demonstrates same behavior as the previously designed theoretical structure
- Disparity in experimental and theoretical performance could be explained by interface effects between VO₂ and Si, or by temperature-dependent optical properties for Si



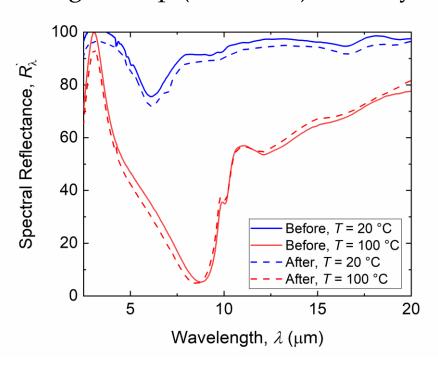
FP Emitter Temperature Stability







High Temp (T = 200 C) Stability



Before and after measurements for both samples are nearly identical, indicating good temperature stability for spacecraft thermal control applications



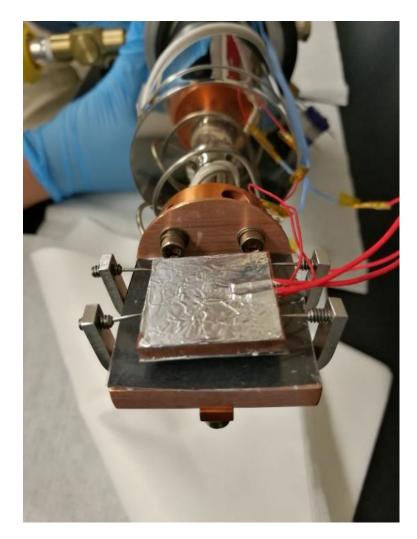


Thermal Vacuum Experiments and Feasibility Studies

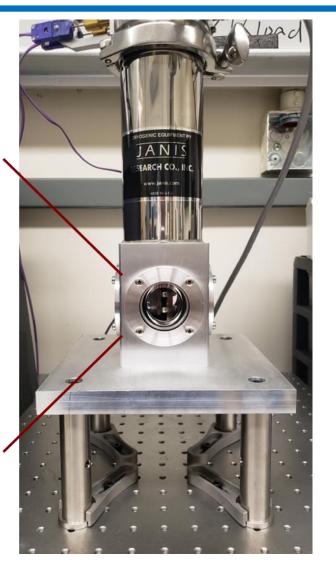


Thermal Vacuum Experiment











Heat Transfer Model



$$\sum Q = 0 = Q_{heater} - Q_{rad} - Q_{sides} - Q_{bot} - Q_{cond}$$

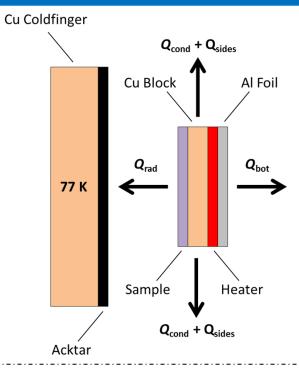
$$Q_{heater} = P_{heater} = I^2 R$$

 $Q_{emiss,theo} = \varepsilon \sigma (T_{\text{sample}}^4 - T_{\text{coldfinger}}^4)$

$$Q_{emiss,exp} = Q_{heater} - Q_{loss}$$

 $\rightarrow Q_{loss}(T)$ is determined from the aluminum measurements:

$$\varepsilon_{AI} = 0.03$$
 \rightarrow $Q_{loss}(T) = Q_{heater} - Q_{emiss,theo}$

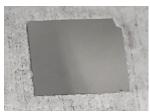


Black (Acktar)



 $\varepsilon_{IR} \approx 93\%$

Aluminum (200 nm on Si) VO₂ FP Emitter



$$\varepsilon_{IR} = 3\%$$

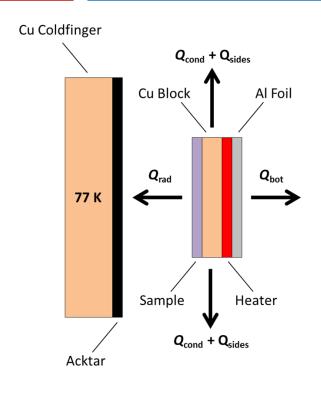


$$\varepsilon_{IR}$$
 = Varies with T

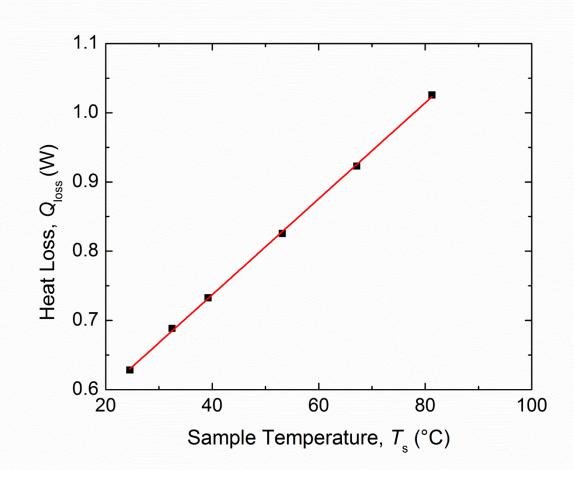


Thermal Vacuum Experiment





$$Q_{loss}(T) = Q_{heater} - Q_{rad}$$
 $Q_{rad} = \epsilon \sigma T_{sample}^4$

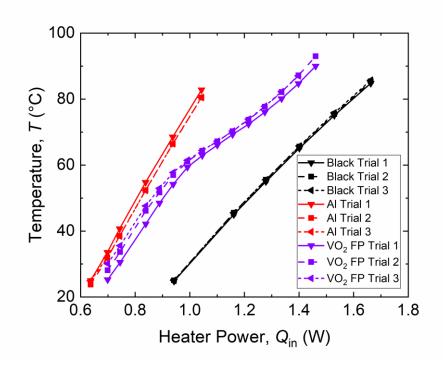


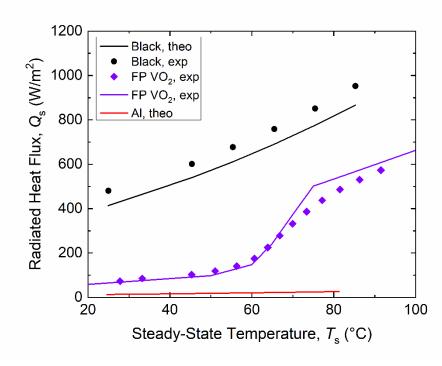
- $Q_{loss}(T_s)$ is described by a linear fit
- Q_{loss} is independent of sample mounted



Thermal Vacuum Experiment







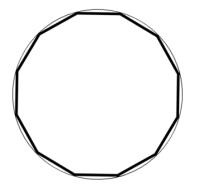
- Clear change in VO₂ FP behavior upon phase transition
- Good agreement between experiment and theoretical prediction
- VO₂ FP emitter varies heat from 72 W/m² at room temp to 570 W/m² at 90 °C



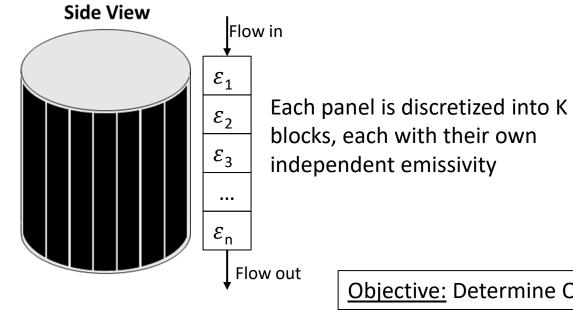
Spacecraft Thermal Systems Modeling

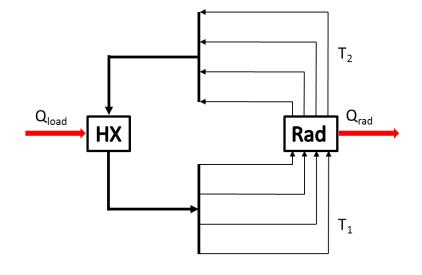


Top View



Body-mounted radiators that are discretized into N = 360 panels





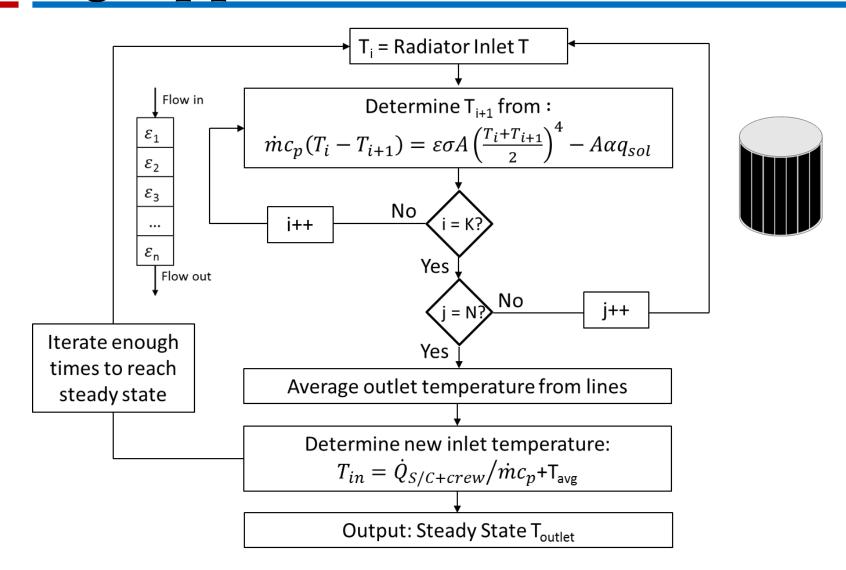
- 1. Fluid picks up heat from HX
- 2. Flow separates into 360 lines with equal flow rates
- 3. Heat is rejected by each separate fluid line/radiator panel
- 4. Flow is mixed to give average T_{outlet}

Objective: Determine Optimum Transition Temperature Range



Coding Approach



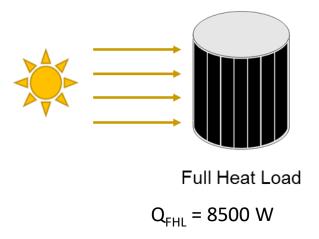




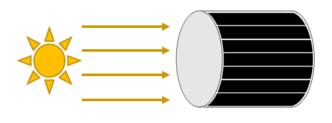
Steady-State Cases Considered



Hot Case



Cold Case



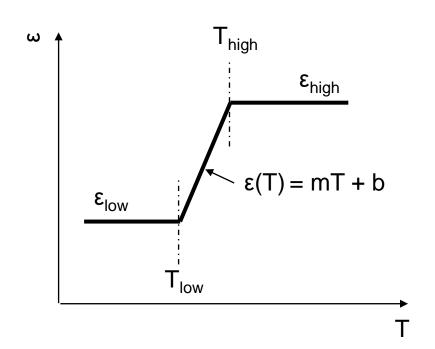
Partial Heat Load

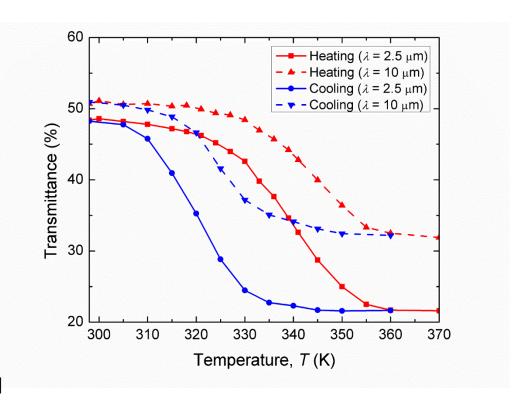
- Requirement 1: Average outlet temperature must be between 0 °C and 10 °C
- Requirement 2: The temperature of each radiator panel must be above -10 °C
- Turndown percentage TD = lowest percentage of full load that can be reduced to while still meeting requirements



Simplified VO₂ Variable Emittance





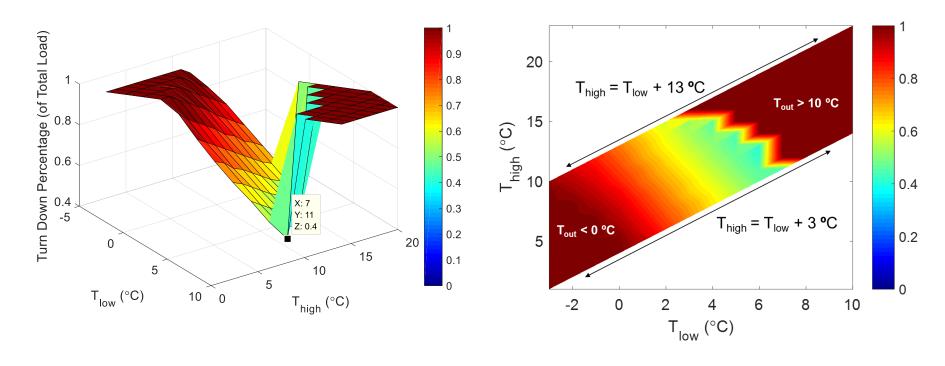


- 1. No hysteresis considered
- 2. ε_{low} can vary between 0.3 and 0.6
- 3. ε_{high} can vary between 0.6 and 0.9
- 4. T_{high} must be between 4 and 20 degrees higher than T_{low}
- \rightarrow (2), (3), and (4) are based on fabrication limitations



Transition Range Optimization





Maximum turn down percentage of 40% occurs when T_{low} = 7 °C and T_{high} = 11 °C

- Optimization ends due to T_{out} going out of bounds
- No cases with freezing as the exit condition





On-going Projects at NASA



ASU VO₂ Variable Emittance



Tech Dev Project Objective:

Develop a thermochromic variable emittance coating based on W-doped VO₂ and a solar filtering layer

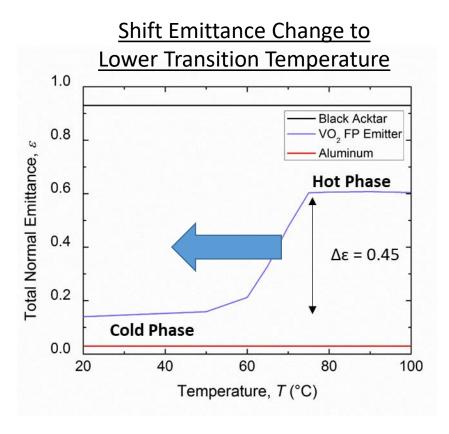
1-D PhC Solar Filter

Low *n*High *n*Low *n*High *n*

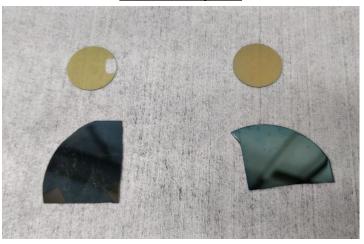
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Low *n*



First round of sputtered VO₂ thin film samples



<u>Temperature-dependent Reflectance</u> and Transmittance Measurements







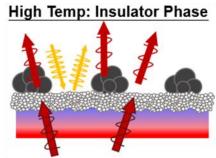
LSM Variable Emittance NSTGRO RC

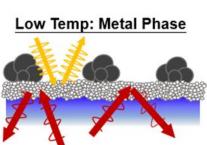


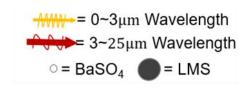
NSTGRO Project Objective:

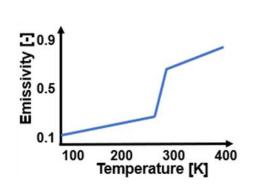
Develop a thermochromic variable emittance coating based on BaSO₄ white paint and LSM nanoparticles



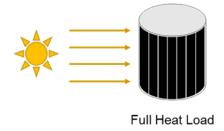




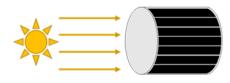


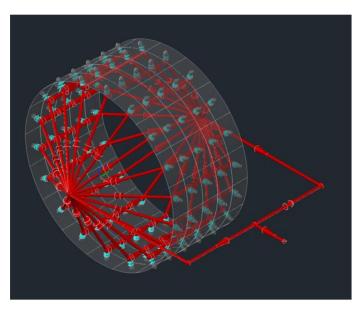


Hot Case









Variable Emittance Modeling Objective:

Determine transition temperature, emittance change, solar absorptance, etc. for the coating to be useful for spacecraft thermal control applications (both human and robotic)



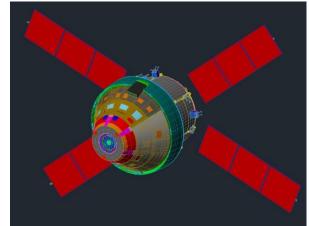
Orion Passive Thermal Control

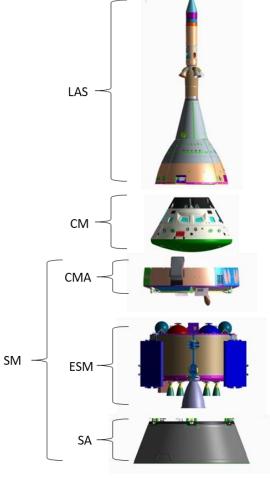










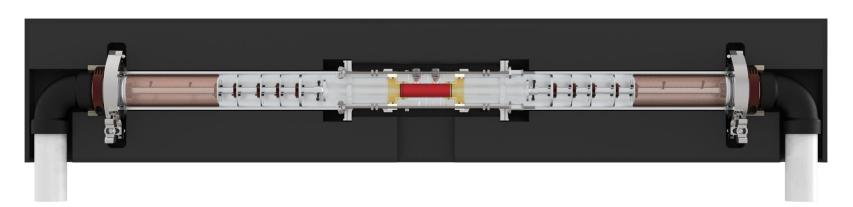




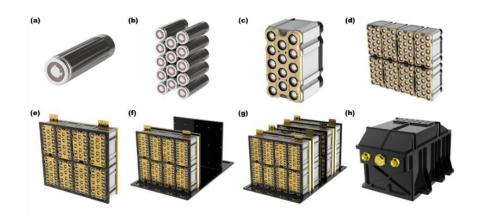


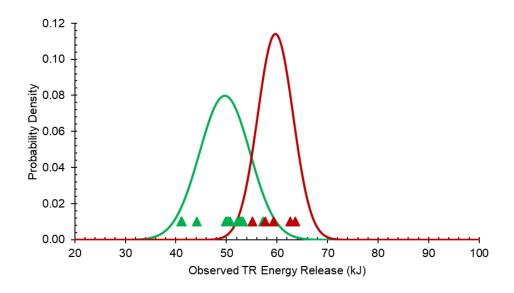
Battery Thermal Runaway Analysis and Testing







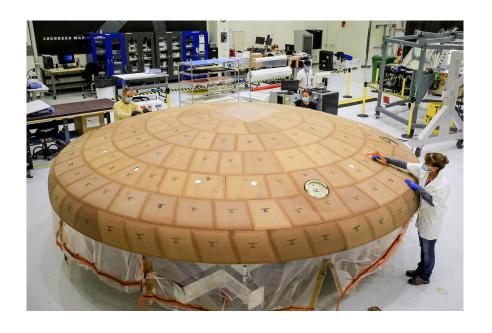




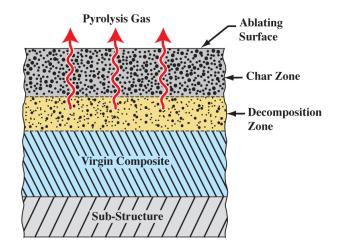


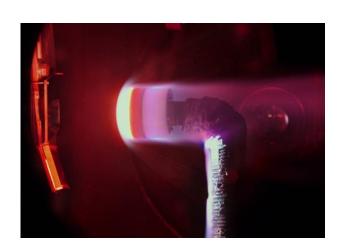
Orion and 3D Printed Thermal Protection Systems

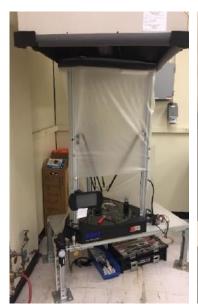


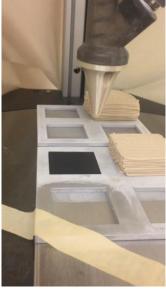
















Thermal Technology Gaps



2020 NASA Technology Taxonomy



→Great resource for understanding what capabilities NASA has identified as necessary to complete our missions



Technology Areas:

TX01: Propulsion Systems

TX02: Flight Computing and Avionics

TX03: Aerospace Power and Energy Storage

TX04: Robotic Systems

TX05: Communications, Navigation, and Orbital Debris Tracking and Characterization Systems

TX06: Human Health, Life Support, and Habitation Systems

TX07: Exploration Destination Systems

TX08: Sensors and Instruments

TX09: Entry, Descent, and Landing

TX10: Autonomous Systems

TX11: Software, Modeling, Simulation, and Information Processing

TX12: Materials, Structures, Mechanical Systems, and Manufacturing

TX13: Ground, Test, and Surface Systems

TX14: Thermal Management Systems

TX15: Flight Vehicle Systems

TX16: Air Traffic Management and Range Tracking Systems

TX17: Guidance, Navigation, and Control



TX14.2 Thermal Control Components and Systems



- Thermal control phase change materials
 - → Need higher latent heat of fusion materials and PCM architectures that lead to high energy absorption per storage volume solutions on spacecraft.



- → Need thermal interfaces with predictable and repeatable interface conductances in different environments (lab versus spacecraft). Spacecraft application typically cannot apply high pressure.
- High power density, long lifetime, space-qualified heater systems
 - → Need robust high watt density heaters, especially for non-planar surfaces.
- Full-field, Full Structure Instrumentation
 - → Need instrumentation for stagnant fluid lines, high stress areas on structure, and high temperature structures.











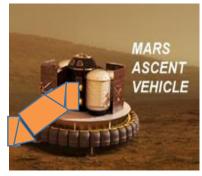


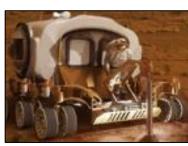
TX14.2 Thermal Control Components and Systems



- Fully-integrated Multiphysics modeling
 - → Need ability to simultaneously model thermal and mechanical behavior of spacecraft.
- Dust Mitigation for thermal control surfaces
 - → Need a way to mitigate degradation of thermal control surfaces due to accumulation of dust.
- Active/passive optical property control
 - → Need to tailor optical properties of thermal control coatings based on external environment or internal heat load.
- Fully integrated thermal control systems
 - → Need to have thermal control components (heating elements, cold plates, heat pipes) embedded in structure.
- High energy passive transport
 - → Need ability to move large amounts of heat to a needed location or heat rejection site.









TX14.X Other Thermal Management Systems



- EDL flight vehicle (aeroshell) flight performance data for human Mars entry and Earth return
 - → Need instrumentation to obtain flight vehicle performance data such as:
 - Pressure
 - Temperature
 - Heat flux
 - Radiation
 - Spectra from mid-IR to VUV
 - Strain
 - TPS recession/in-depth response
- Efficient, rapid processing of ultra-large thermal/fluid/propulsion databases
 - → Need efficient, rapid processing of >100 Gb up to 1 Tb thermal/fluid/propulsion databases to enhance autonomous control





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